



Summary

In this work we propose a polarization beam splitter based on an advanced SWG metamaterial topology which controls the propagation of multiple TE and TM modes at the same time. The proposed device achieves a simulated insertion loss <1 dB and extinction ratio >20 dB over a 400 nm bandwidth.

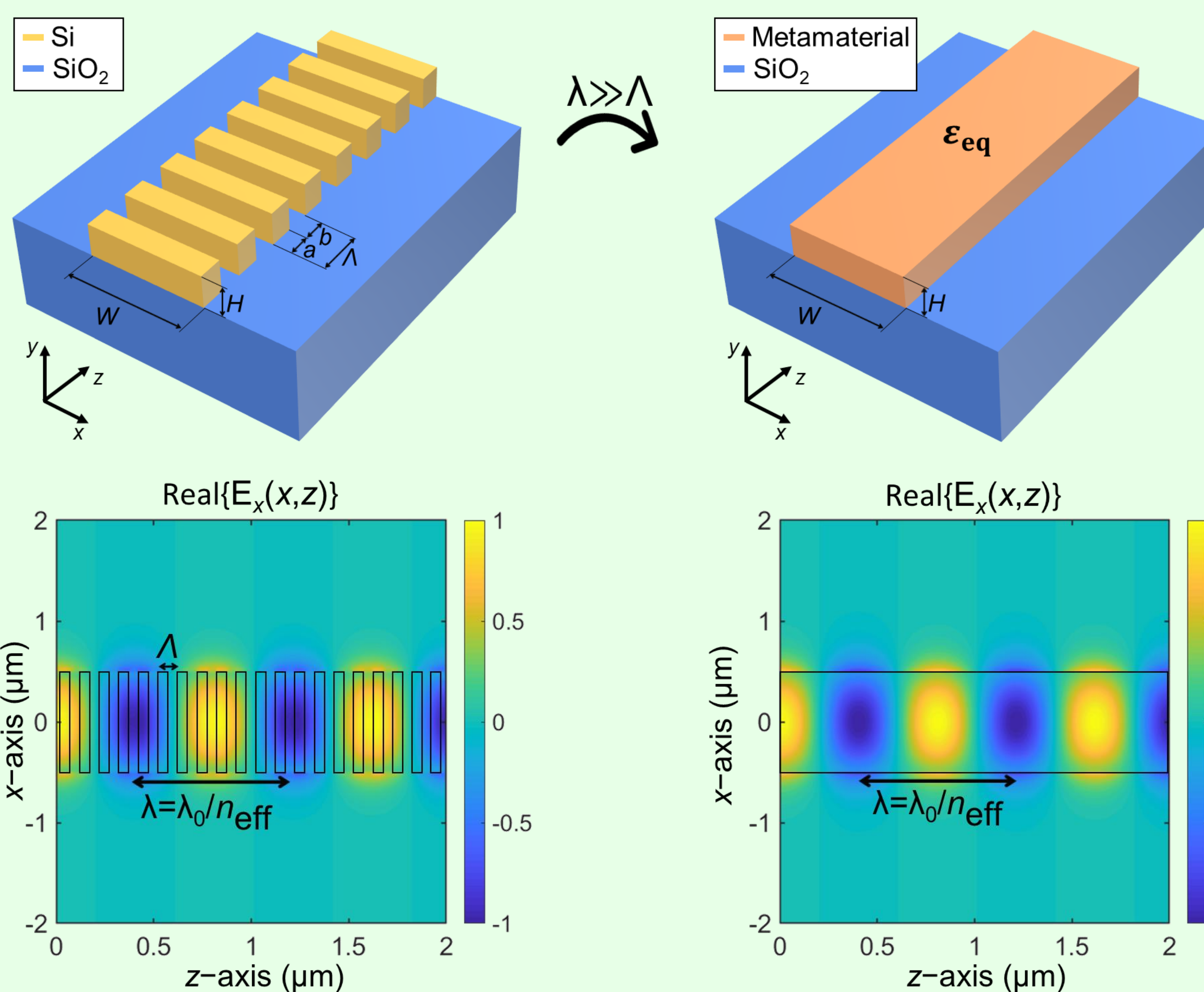
Silicon photonics and SWG metamaterials

Silicon photonics is leading the landscape of integrated photonics, with Silicon-On-Insulator (SOI) platform having important commercial applications specially on the data/telecom industry [1].

The huge success of SOI principally comes from its high integration density and the compatibility of the fabrication process of SOI chips with the CMOS process

However, CMOS compatibility comes with the drawback of restricting the available materials to those compatible with the fabrication process, hindering the design of high-performance devices.

Subwavelength grating (SWG) metamaterials circumvent the restriction on the available materials by behaving as homogeneous anisotropic material with tailorable optical properties [2].



The condition for a periodic structure to work as a homogeneous metamaterial is:

$$\Lambda < \lambda_0 / 2n_{\text{eff}}$$

The homogeneous metamaterial equivalent to an SWG structure is characterized by its permittivity tensor:

$$\epsilon_{\text{eq}} = \begin{bmatrix} n_{xx}^2 & 0 & 0 \\ 0 & n_{yy}^2 & 0 \\ 0 & 0 & n_{zz}^2 \end{bmatrix}$$

These tensor components can be calculated in a first approach as:

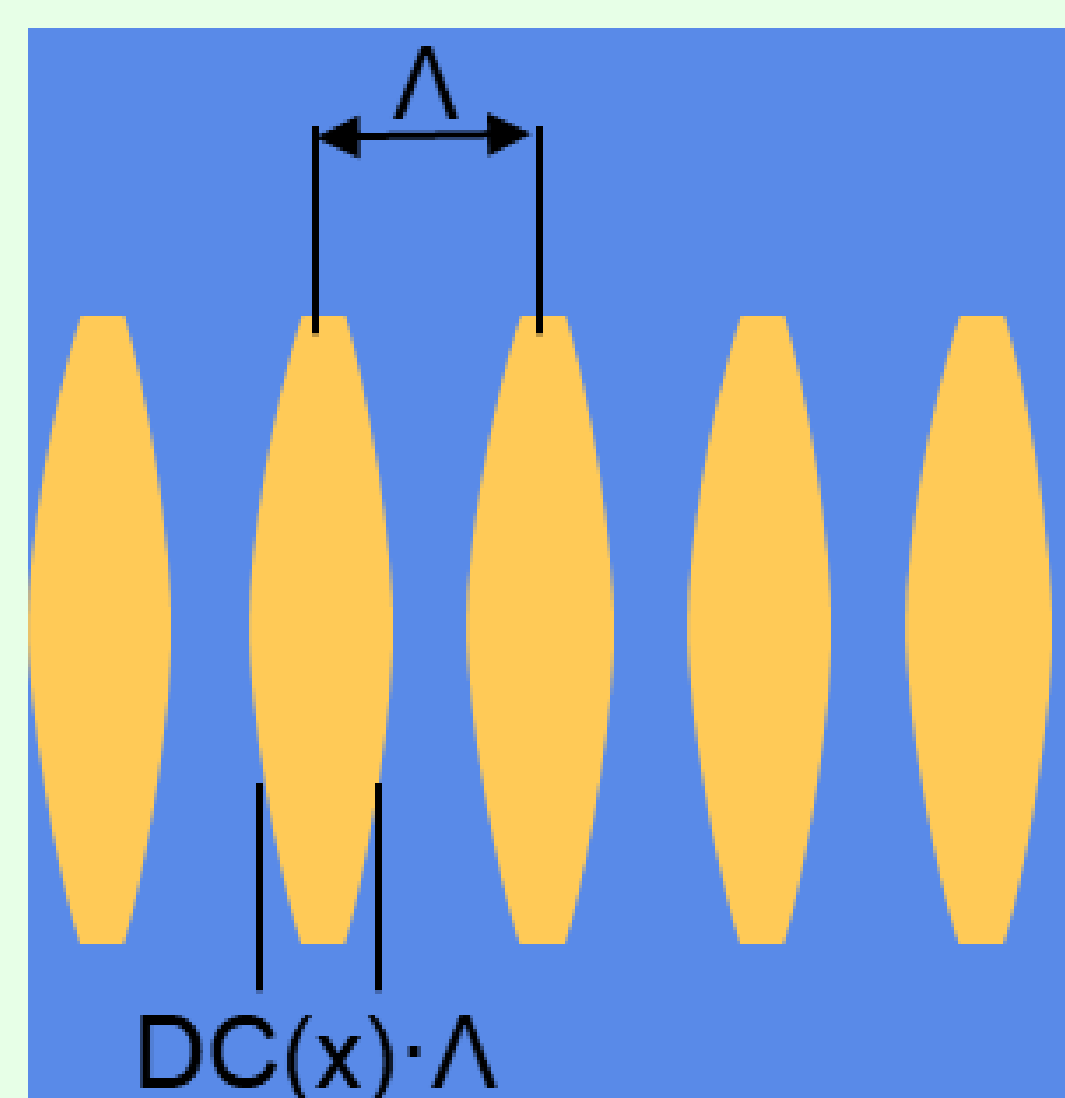
$$n_{xx}^2 = n_{yy}^2 = DC \cdot n_{\text{Si}}^2 + (1-DC) \cdot n_{\text{SiO}_2}^2$$

$$n_{zz}^2 = DC/n_{\text{Si}}^2 + (1-DC)/n_{\text{SiO}_2}^2$$

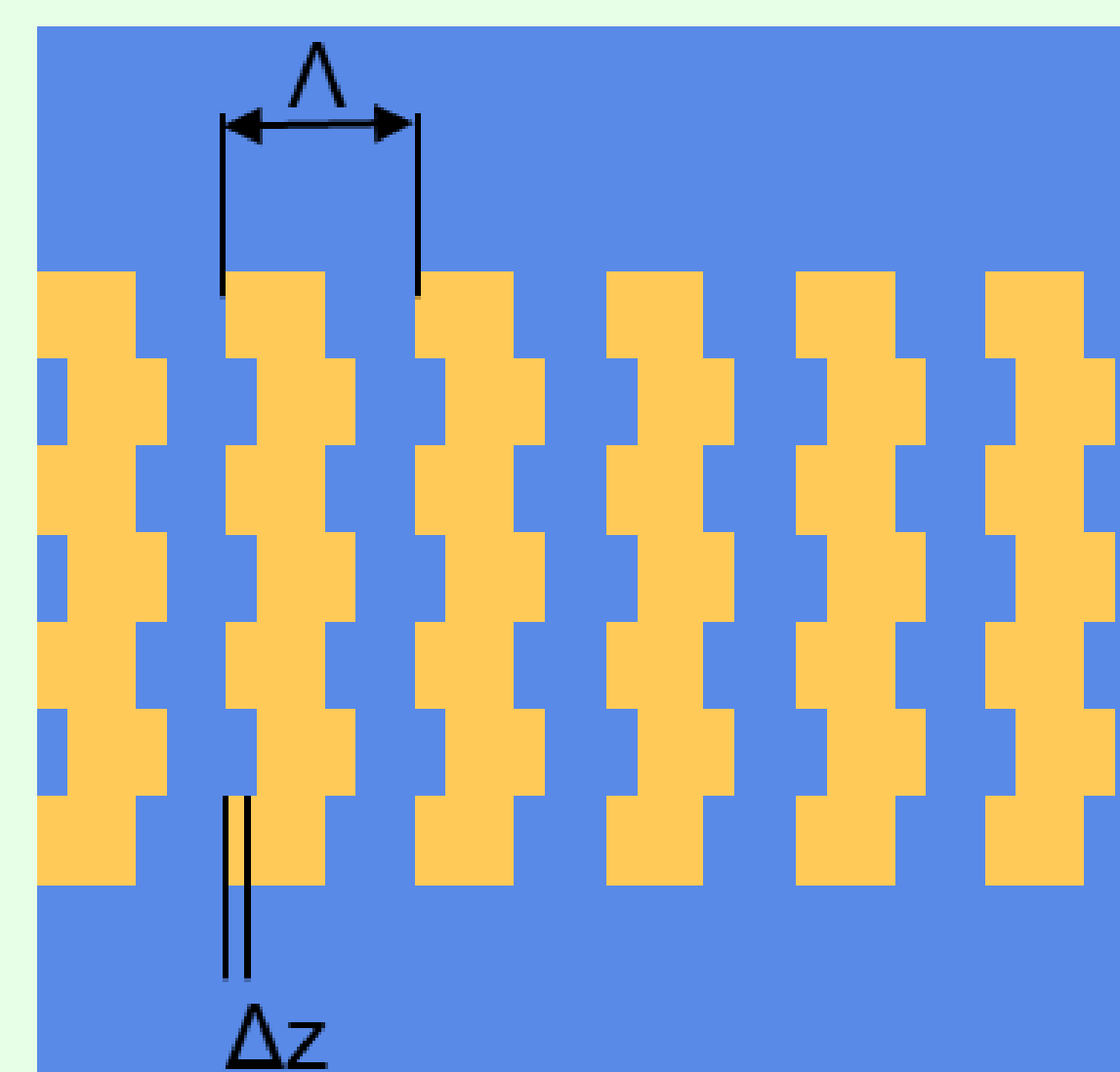
Advanced SWG metamaterials topologies

Gradual subwavelength gratings [3] offer virtually complete control over light propagation in photonic chips.

Bricked subwavelength gratings [4] are auspicious structures to control the TE polarization without affecting TM.



$$\epsilon_{\text{eq}} = \begin{bmatrix} n_{xx}^2(x) & 0 & 0 \\ 0 & n_{yy}^2(x) & 0 \\ 0 & 0 & n_{zz}^2(x) \end{bmatrix}$$

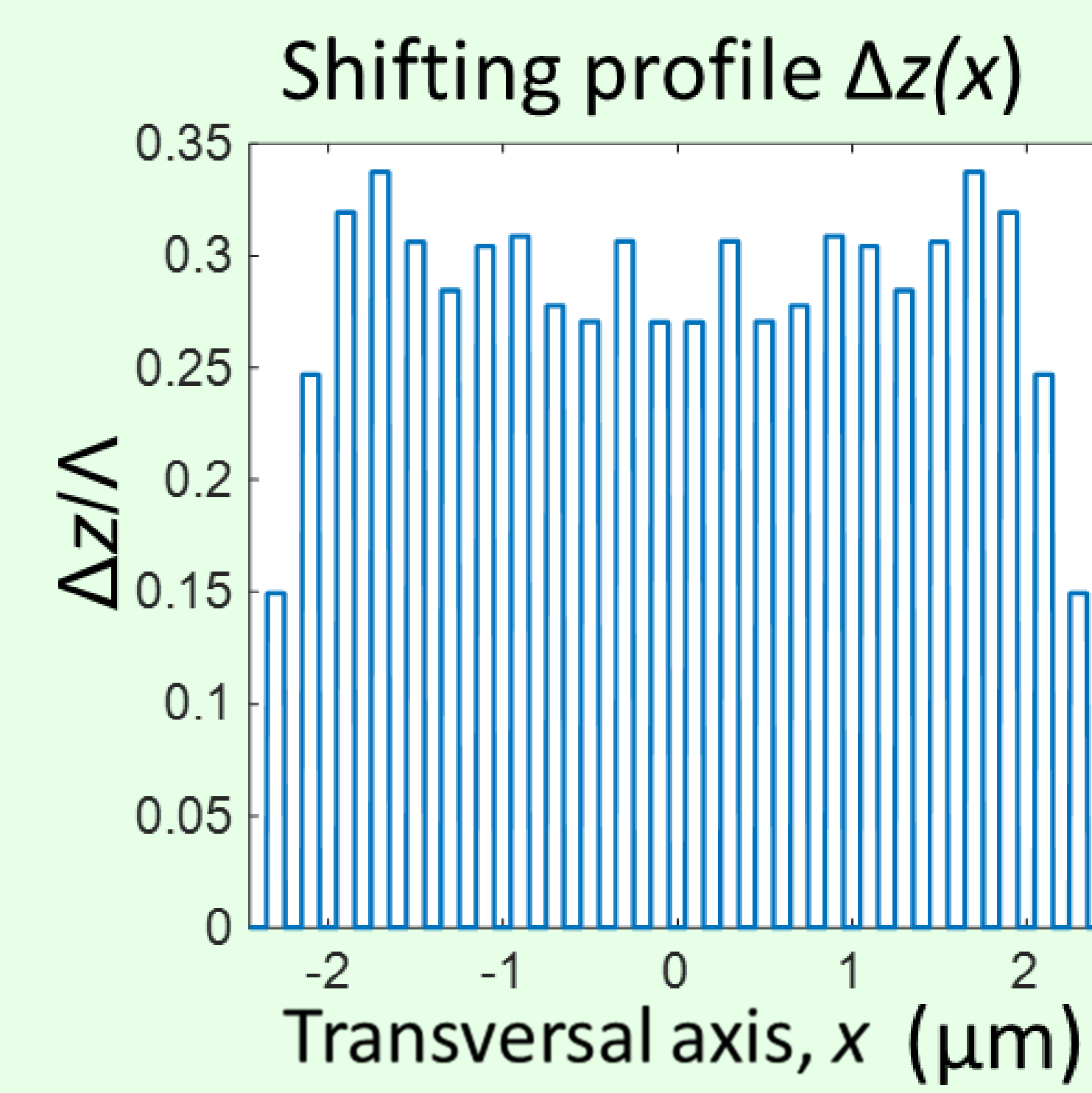
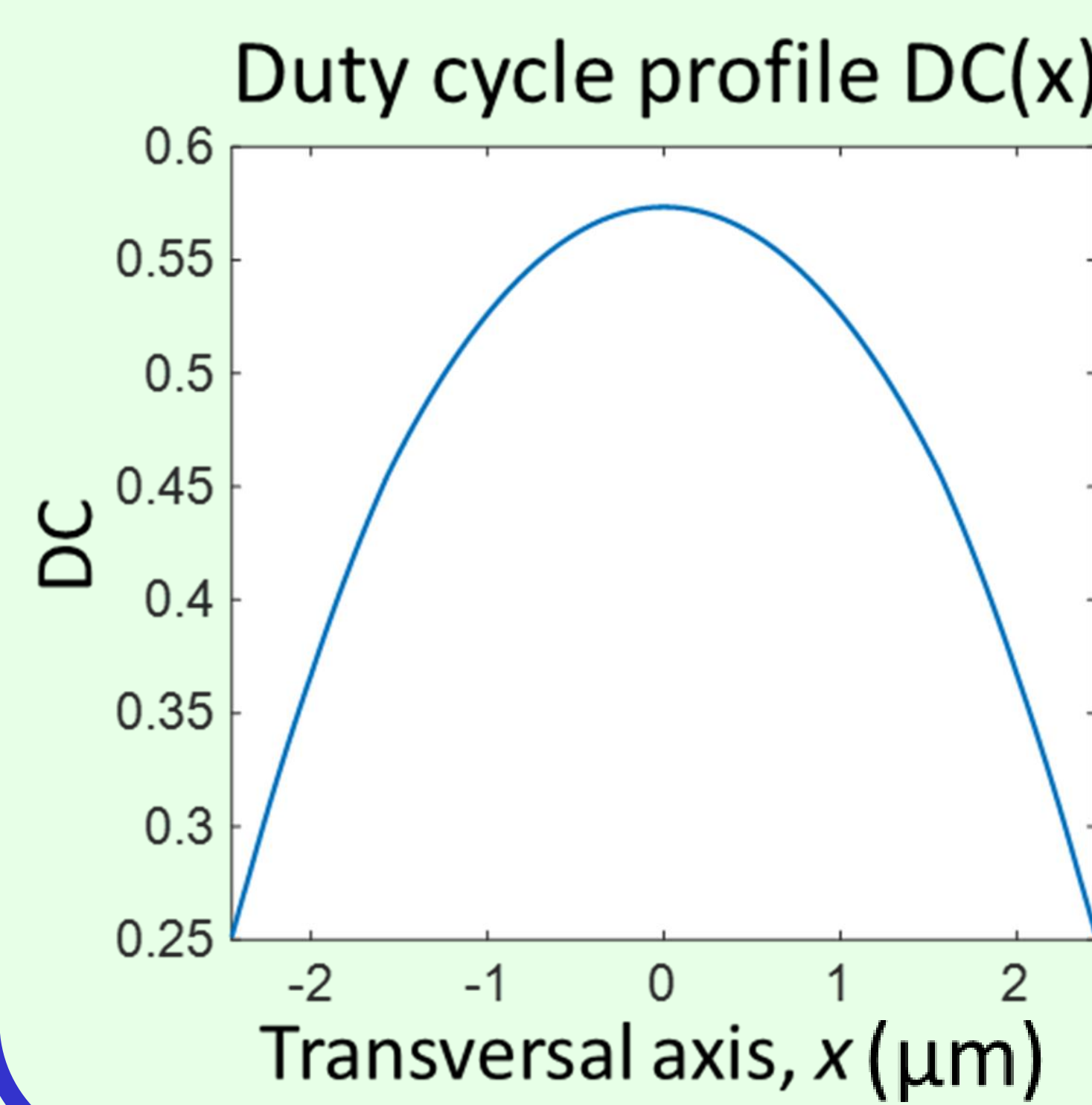


$$\epsilon_{\text{eq}} = \begin{bmatrix} n_{xx}^2(\Delta z) & 0 & 0 \\ 0 & n_{yy}^2 & 0 \\ 0 & 0 & n_{zz}^2(\Delta z) \end{bmatrix}$$

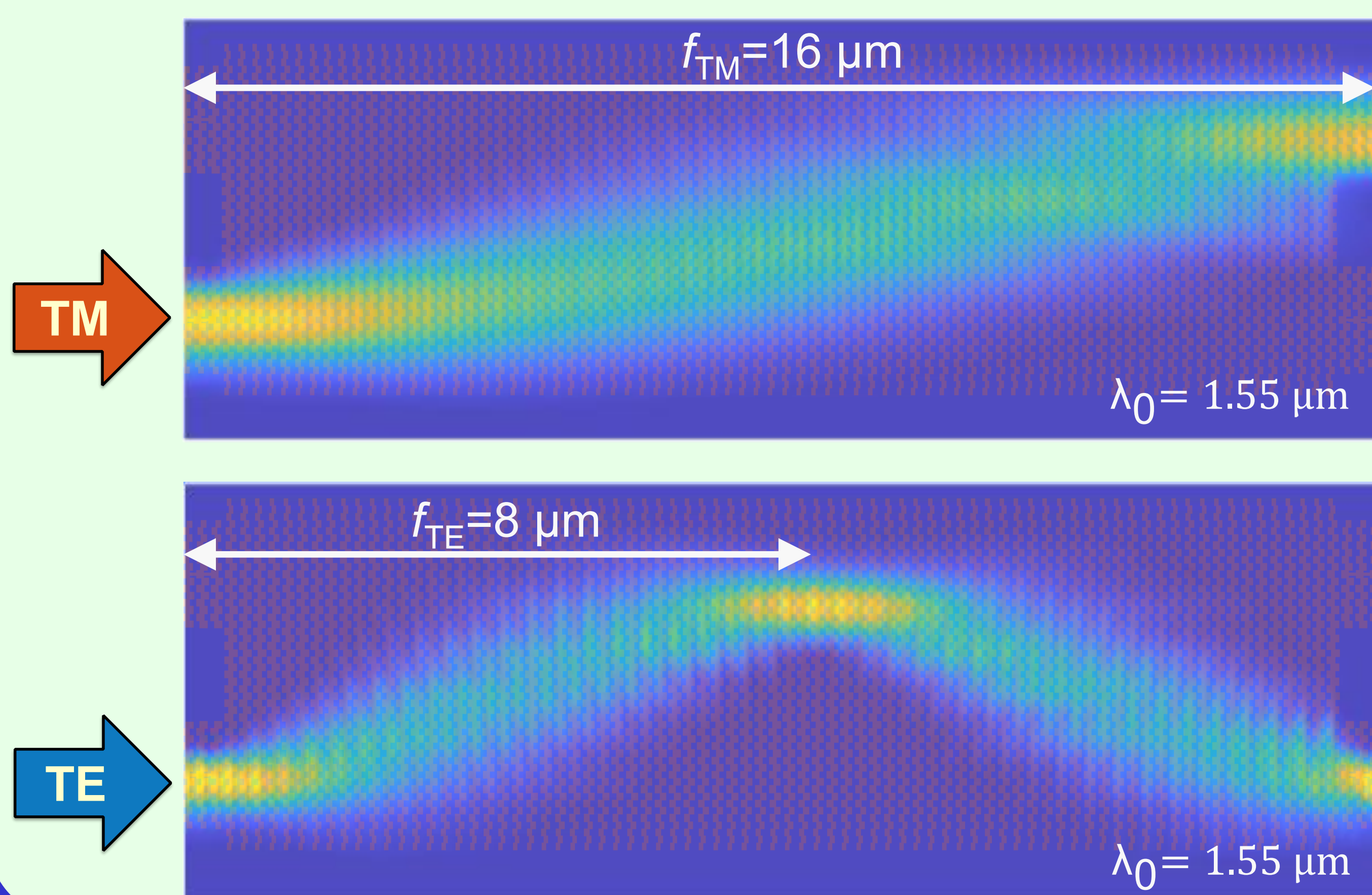
Design of a GRIN bricked lens

The gradualness profile on the duty cycle, DC(x), enables the implementation of a GRIN lens working for both polarizations with focus lengths, f_{TE} and f_{TM} .

The shifting profile of the bricked topology, $\Delta z(x)$, enables the tuning of the TE focal length, enabling to satisfy the polarization splitting condition: $2f_{\text{TE}} = f_{\text{TM}}$

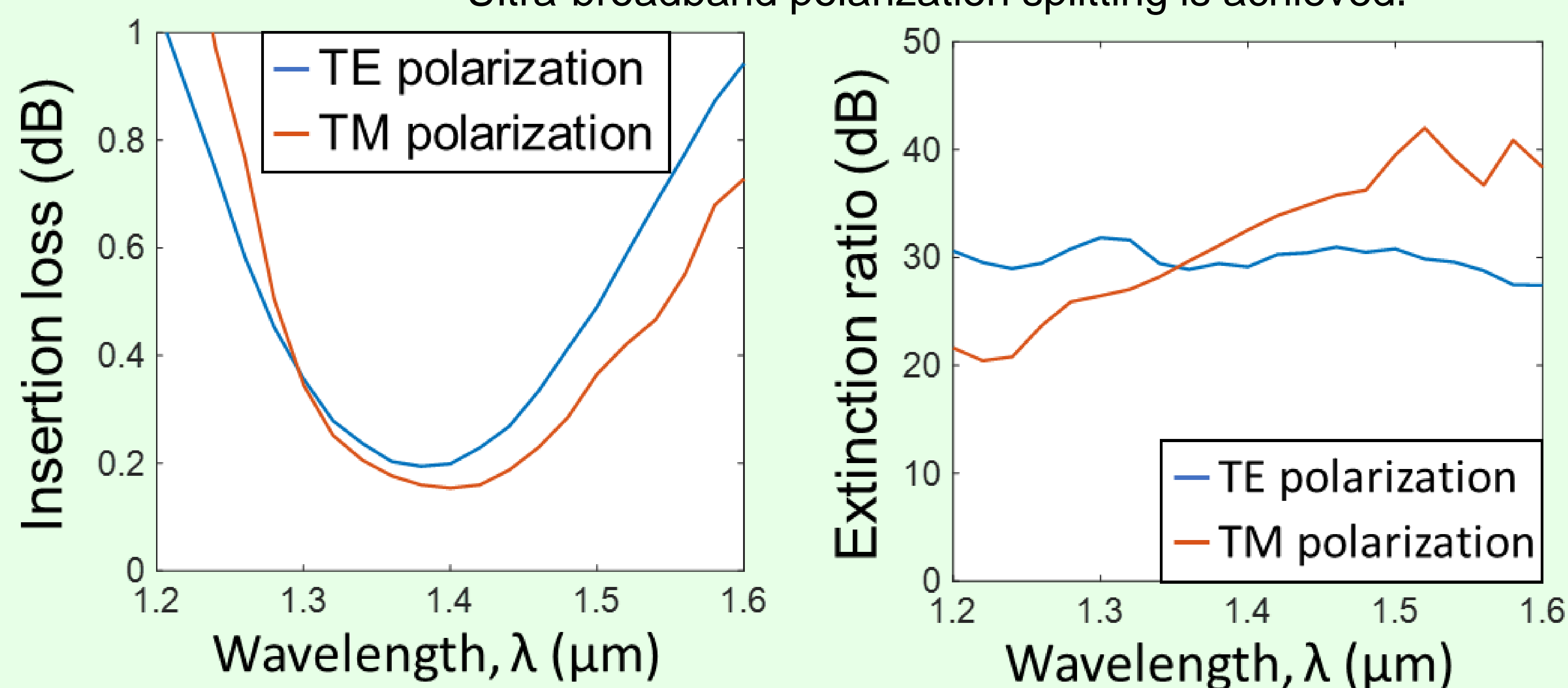


Simulation of a GRIN bricked lens polarization beam splitter



The focus length of GRIN lenses is wavelength independent!!!

Ultra-broadband polarization splitting is achieved.



References

- [1] A. Rahim, T. Spuesens, R. Baets, and W. Bogaerts, "Open-Access Silicon Photonics: Current Status and Emerging Initiatives," Proceedings of the IEEE, **106** 12, (2018)
- [2] J. M. Luque-González, A. Sánchez-Postigo, et al, "A review of silicon subwavelength gratings: building break-through devices with anisotropic metamaterials," Nanophotonics, **10**, 11, (2021)
- [3] J. M. Luque-González, A. Ortega-Moñux, et al, "Bricked Subwavelength Gratings: A Tailorable On-Chip Metamaterial Topology," Laser & Photonics Reviews, **15**, 6, (2021)
- [4] J. M. Luque-González, R. Halir, et al, "An Ultracompact GRIN-Lens-Based Spot Size Converter using Subwavelength Grating Metamaterials," Laser & Photonics Reviews, **13**, 11, (2019)